



OMB No. 0651-0011

INFORMATION DISCLOSURE CITATION
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Page 1 of 2

Atty. & Trademark No.
01222.0034-00000Serial No.
08/544,212Applicant
David A. RUSSO et al.Filing Date
October 17, 1995Group
Unknown

U.S. PATENT DOCUMENTS

*Examiner Initial	Document Number	Date	Name	Class	Sub Class	Filing Date If Appropriate
MM	RE 31,708	10/16/84	Gordon			
	2,617,741	11/11/52	Lytle			
	3,378,396	04/16/68	Zaromb			
	3,410,710	11/12/68	Mochel			
	3,460,960	08/12/69	Francel et al.			
	3,674,453	07/04/72	Loukes et al.			
	3,681,042	08/01/72	Edwards et al.			
	3,706,485	12/19/72	Fawcett et al.			
	3,710,074	01/09/73	Stewart			
	3,846,152	11/05/74	Franz			
	3,885,855	05/27/75	Gross			
	3,889,026	06/10/75	Groth			
	3,900,609	08/19/75	Wille			
	3,934,587	01/27/76	Gordon			
	3,962,062	06/08/76	Ingrey			
	3,984,581	10/05/76	Dobler et al.			
	4,107,426	08/15/78	Gordon			
	4,146,657	03/27/79	Gordon			
	4,187,336	02/05/80	Gordon			
	4,206,252	06/03/80	Gordon			
	4,227,929	10/14/80	Law et al.			
	4,265,974	05/05/81	Gordon			
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	4,338,482	07/06/82	Gordon			
	4,348,453	09/07/82	Cohen			
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	4,377,613	03/22/83	Gordon			
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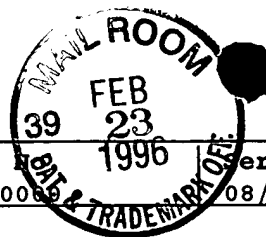
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Date Considered

6/2/96

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Page 2 of 2

Atty. Docket 01222.0034-0006 Serial No. 08/544,212
Applicant David A. RUSSO et al.
Filing Date October 17, 1995 Group Unknown

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AM	4,585,674	04/29/86	Gordon			
	4,590,096	05/20/86	Lindner			
	4,595,634	06/17/86	Gordon			
	4,612,217	09/16/86	Gordon			
	4,628,005	12/09/86	Ito et al.			
	4,652,463	03/24/87	Peters			
	4,661,381	04/28/87	Callies et al.			
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						Yes	No
AM	58-189263	04/28/82	Japan			X	
	57-34164	08/06/80	Japan			X	
	833649	02/12/79	USSR			X	
	84/02128	06/07/84	PCT			X	
	2,031,756	02/12/79	U.K.			X	
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AM	Hochberg et al., "User's Guide for Glass Deposition with LTO-410™ Source Material", J.C. Schumacher & Co. (1990)✓
	S.B. Desu, "Decomposition Chemistry of Tetramethoxysilane" (1987)
	S.K. Raju et al., "Analytical Model for the Low Pressure Chemical Vapor Deposition of SiO ₂ from Tetraethoxysilane" ✗p
	Hochberg et al., "The Use of Liquid Sources in CVD Applications: Fire Safety Considerations and Delivery Methods" (1988)✗
	Williams et al., J. Electrochem. Soc. 134(3) 657-64 (1987)✗
AM	Hochberg et al., J. Electrochem. Soc. 136(6) 1843 (1989)✓

Examiner

AM Brunsman

Date Considered

6/28/96

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Sheet 1 of 2

Form PTO-1449
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ATTY. DOCKET NO.

1-13182

SERIAL NO.

08/544,212

INFORMATION DISCLOSURE STATEMENT
BY APPLICANT

(Use several sheets if necessary)

APPLICANT

David A. Russo, et al.

FILING DATE

October 17, 1995

GROUP

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
AMY	3 3 7 8 3 9 6	4/16/68	Zaromb	—	—	
	3 9 4 9 1 4 6	4/6/76	Kane et al. ✓	—	—	
	4 1 8 7 3 3 6	2/5/80	Gordon	—	—	
	4 2 0 6 2 5 2	6/3/80	Gordon	—	—	
	4 3 0 8 3 1 6	12/29/8	Gordon	—	—	
	4 3 2 9 3 7 9	5/11/82	Terneu et al. ✓	—	—	
	4 3 8 6 1 1 7	5/31/83	Gordon	—	—	
	4 4 7 6 1 5 8	10/9/84	Baumberger et al. ✓	—	—	
	4 5 9 0 0 9 6	5/20/86	Lindner	—	—	
	4 6 0 1 9 1 7	7/22/86	Russo et al. ✓	—	—	
MM	4 6 9 6 8 3 7	9/29/87	Lindner	—	—	

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO

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MM	J. Electrochem. Soc., Vol. 136, No. 6, (June 1989); "The LPCVD of Silicon Oxide Films below 400°C from Liquid Sources"; A.K. Hockberg and D.L. O'Meara; Pages 1843-1844.
MM	J. Electrochem Soc.: SOLID-STATE SCIENCE AND TECHNOLOGY, Vol. 134, No. 3; "LPCVD of Borophosphosilicate Glass from Organic Reactants"; D.S. Williams and E.A. Dein; Pages 657-664. ✓

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DM Brunsma

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